

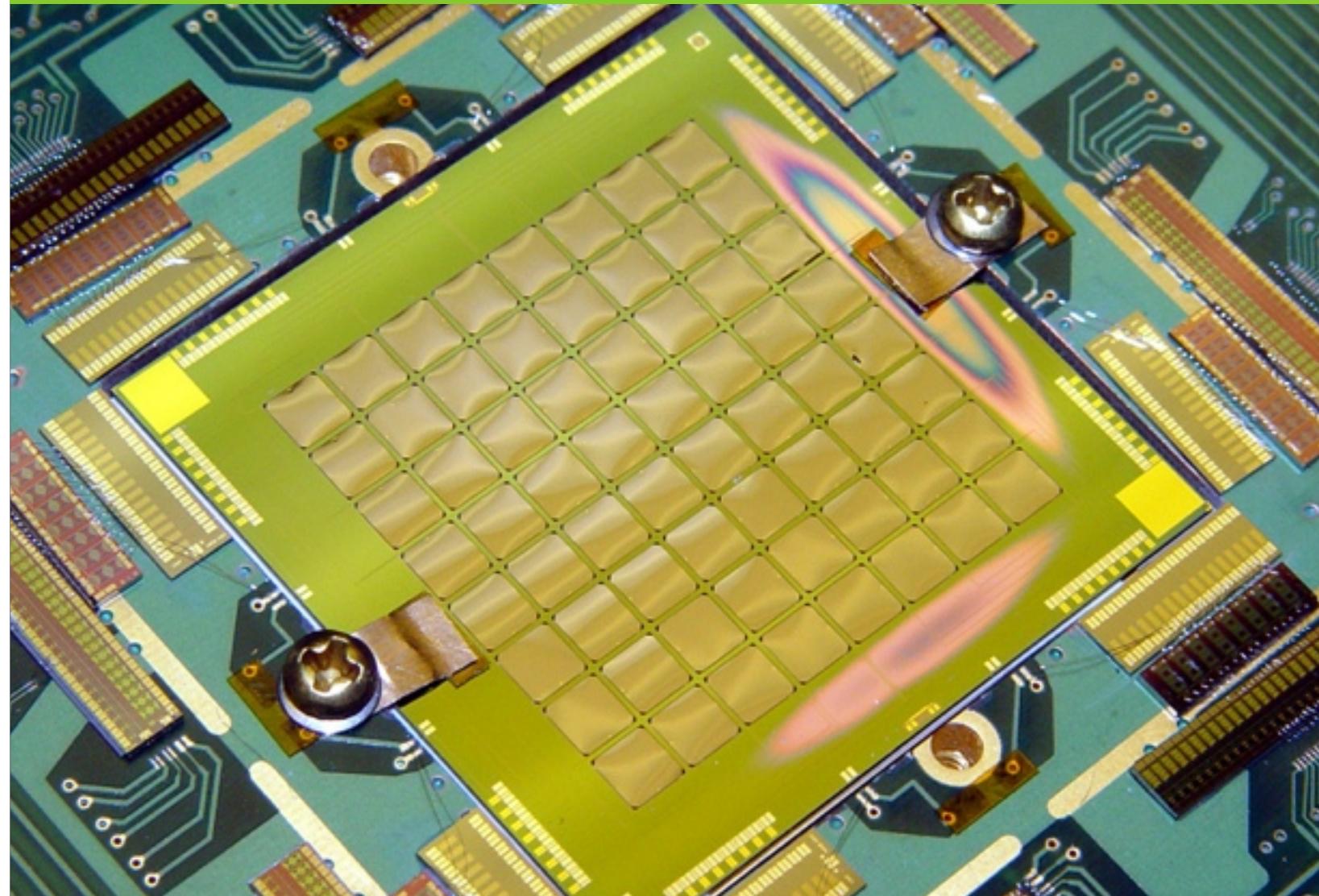
Characterizing the PAR Detectors

Enectali Figueroa-Feliciano, Miriam Huntley,
Youngsoo Park

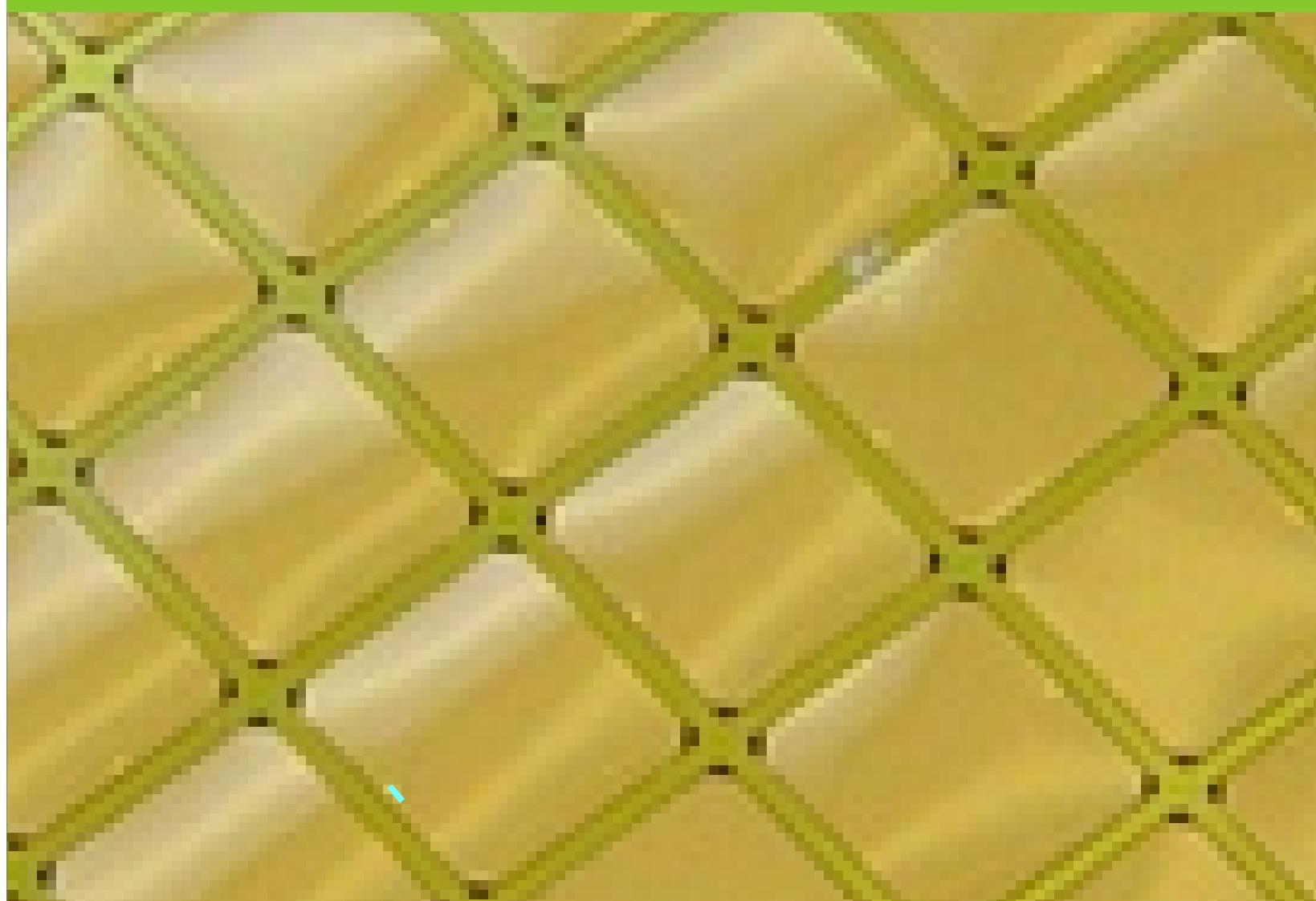
All data from Simon, Phillip, et al. at UPenn



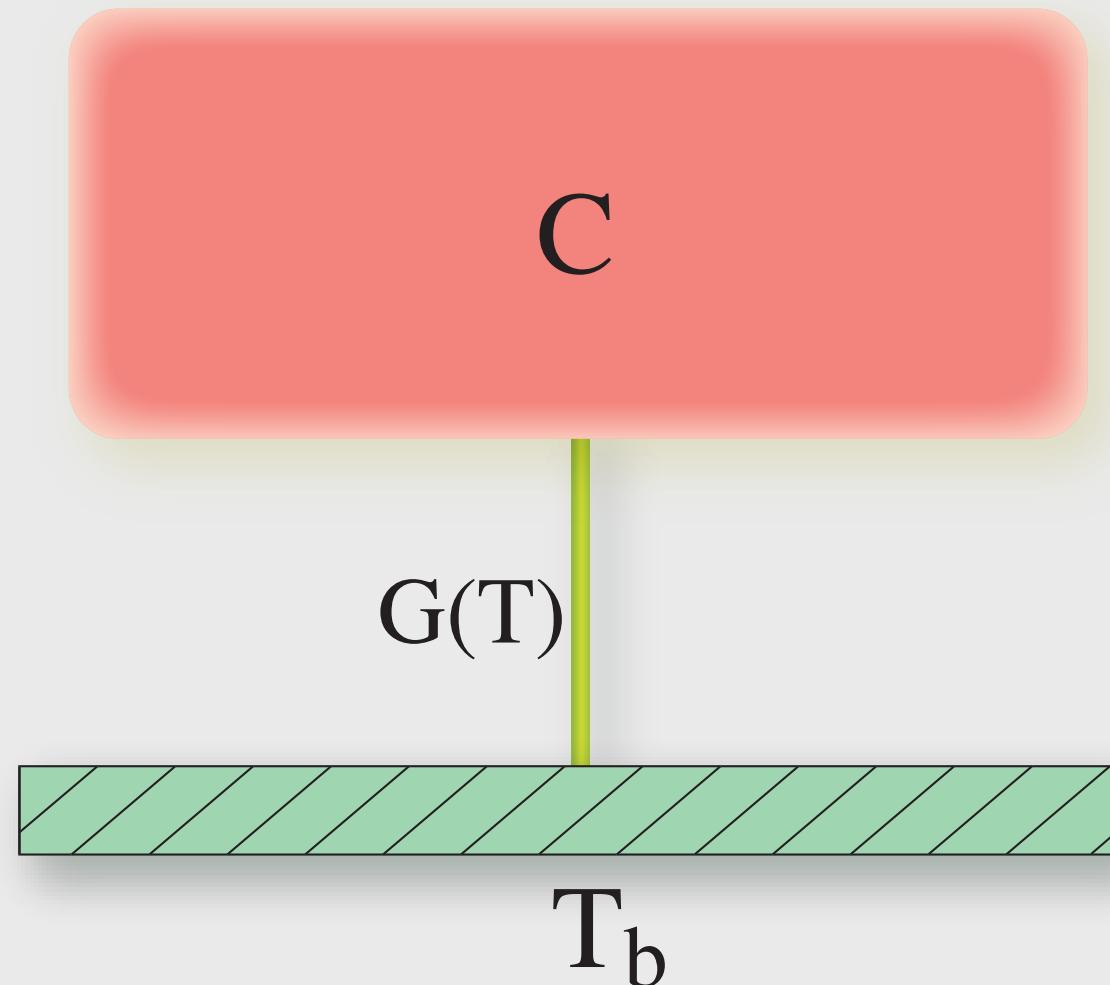
The UPenn Array



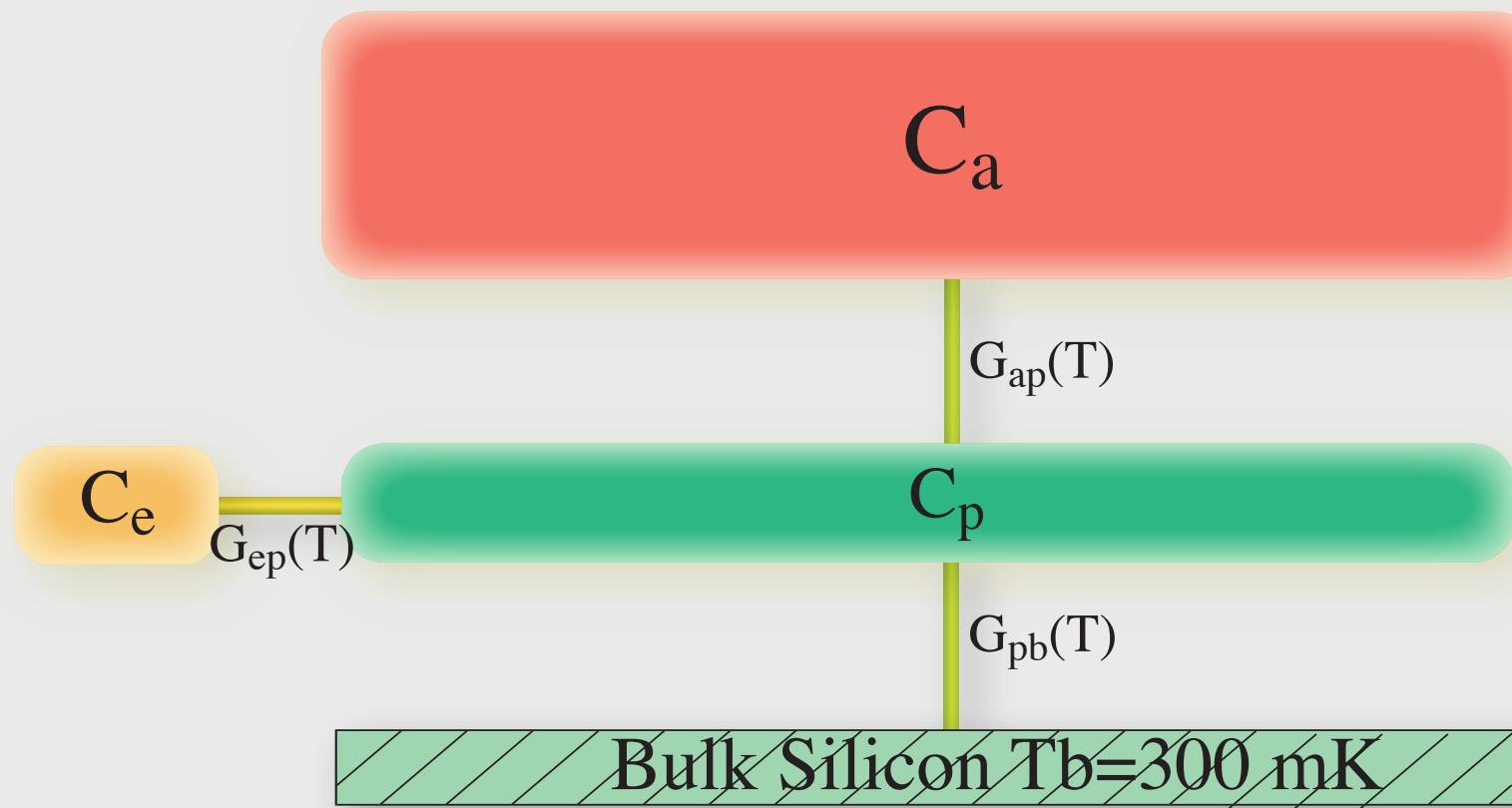
The TESs are Small!



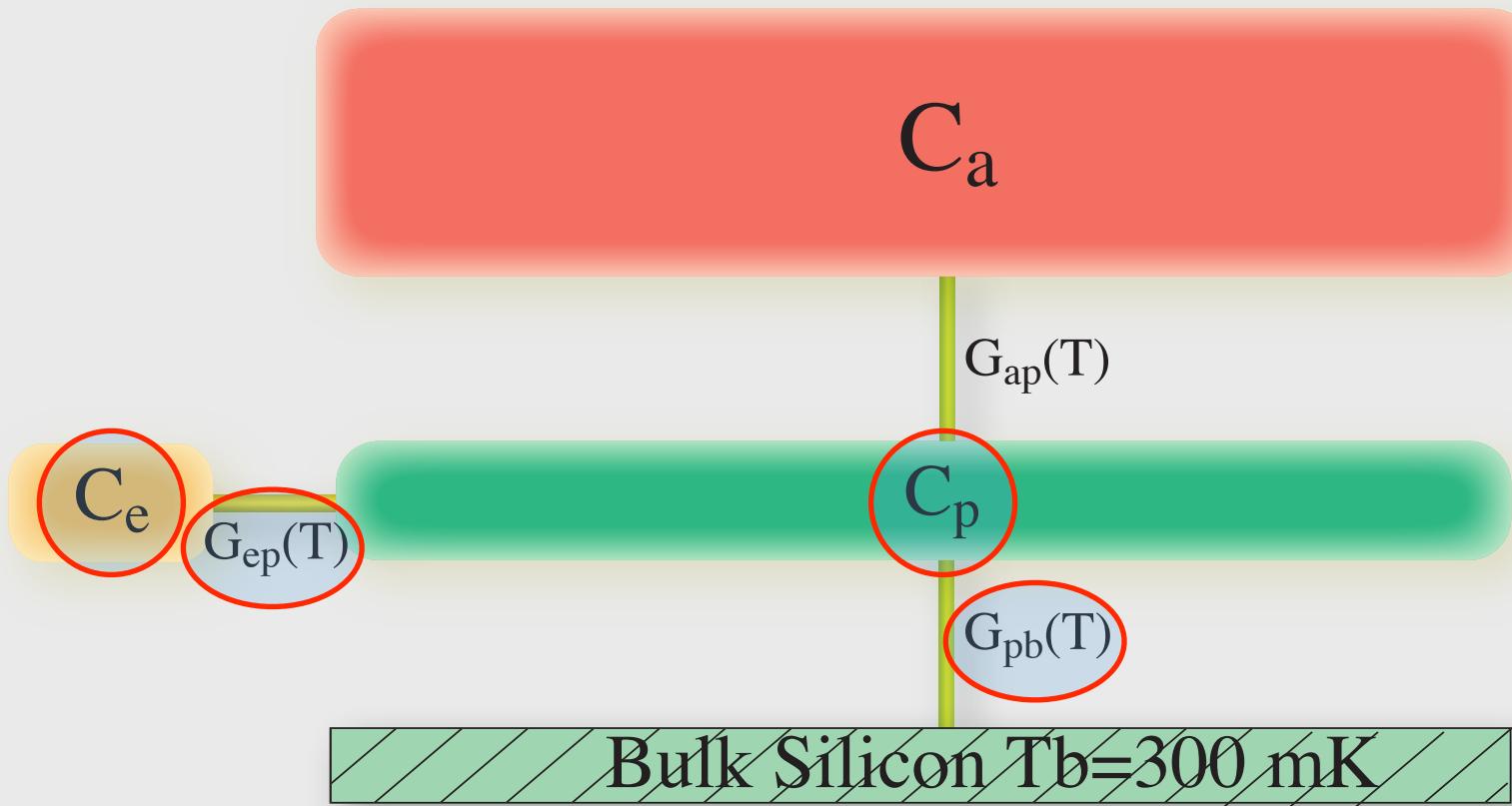
The Ideal Model



A Better Model



Estimating Parameters



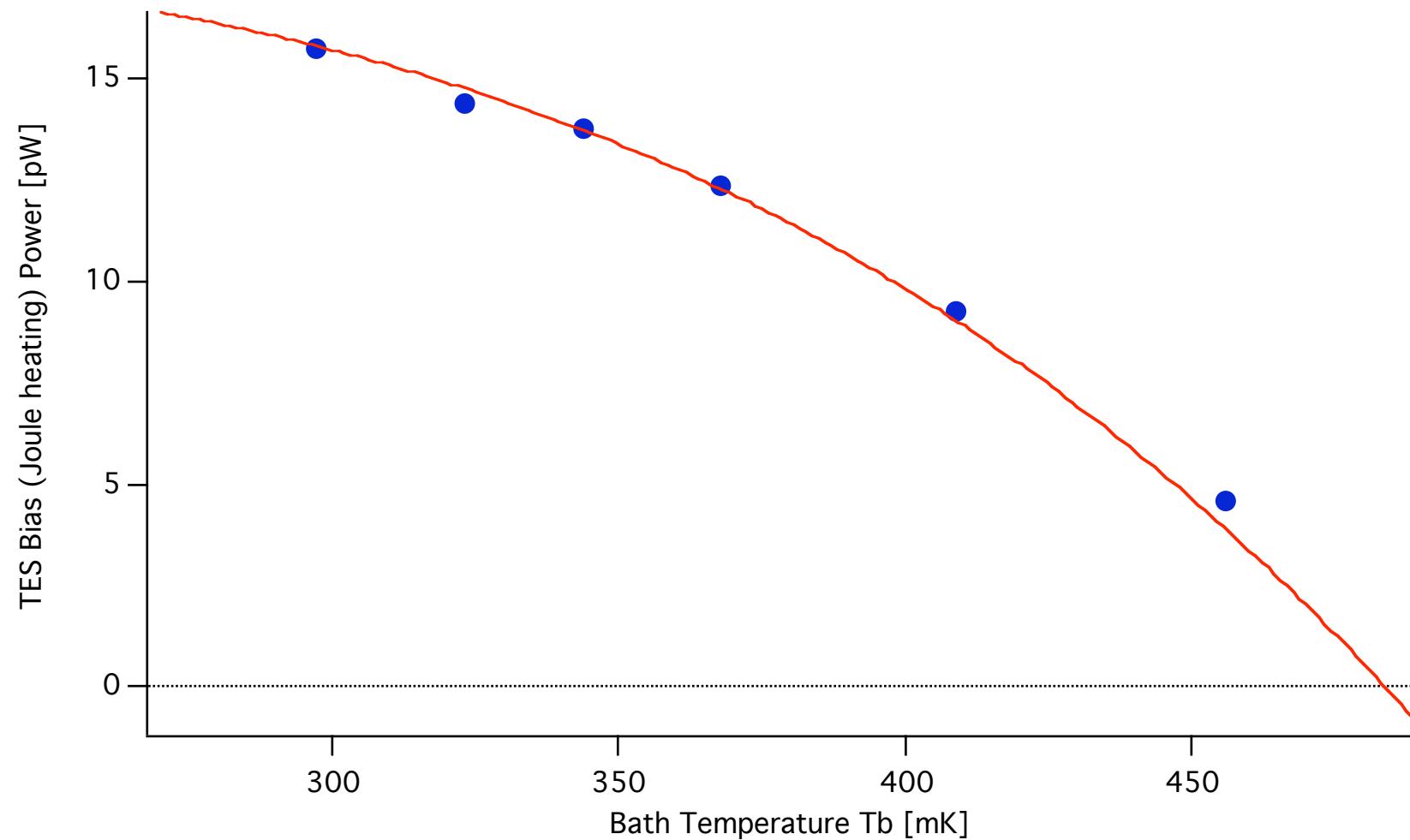
Estimating Parameters

- The TES and phonon heat capacities are calculated from published values of heat capacities for Mo, Au, and Silicon.
- $C_e = 160 \text{ fJ/K}$, $C_p = 650 \text{ fJ/K}$
- The electron-phonon thermal conductance is also estimated from the literature, but there is about a factor of 10 uncertainty in the actual number
- $G_{ep} = 5\text{-}50 \text{ nW/K}$ @ 480 mK

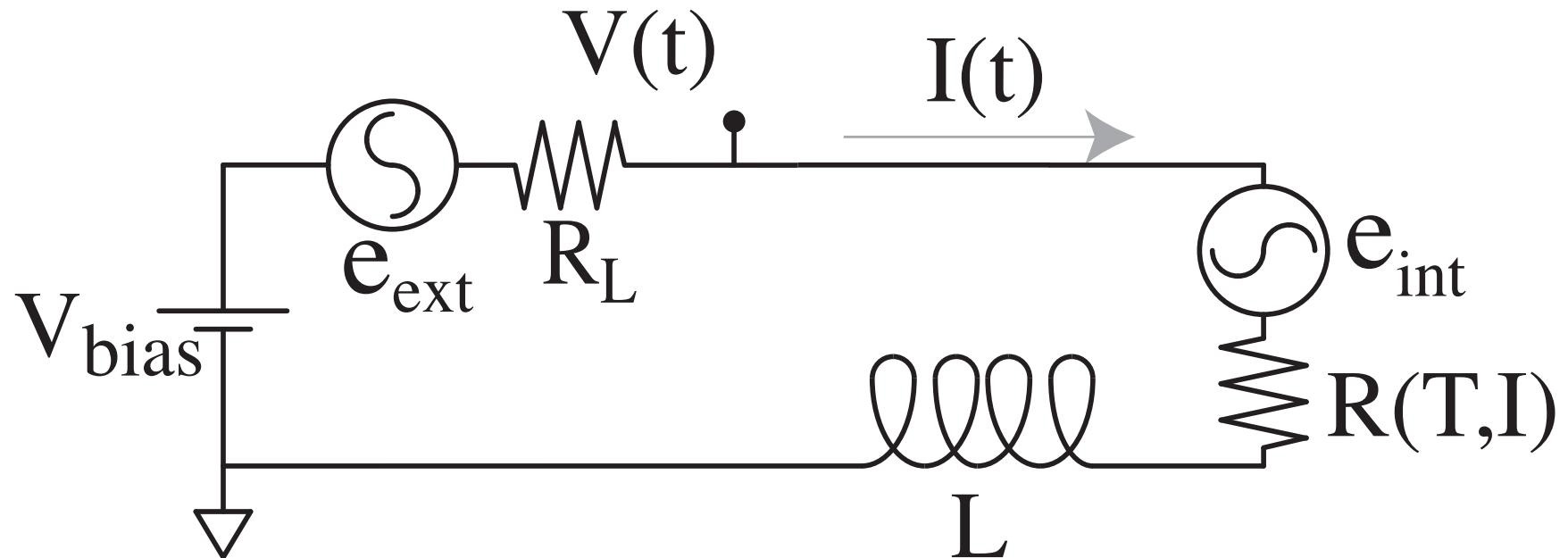
Estimating Parameters

- The thermal conductance to the silicon substrate, G_{pb} , is calculated from fitting the bias power vs bath temperature curve
- $G_{pb} = 140 \text{ pW/K}$ @ 480 mK

Power vs Bath Temperature

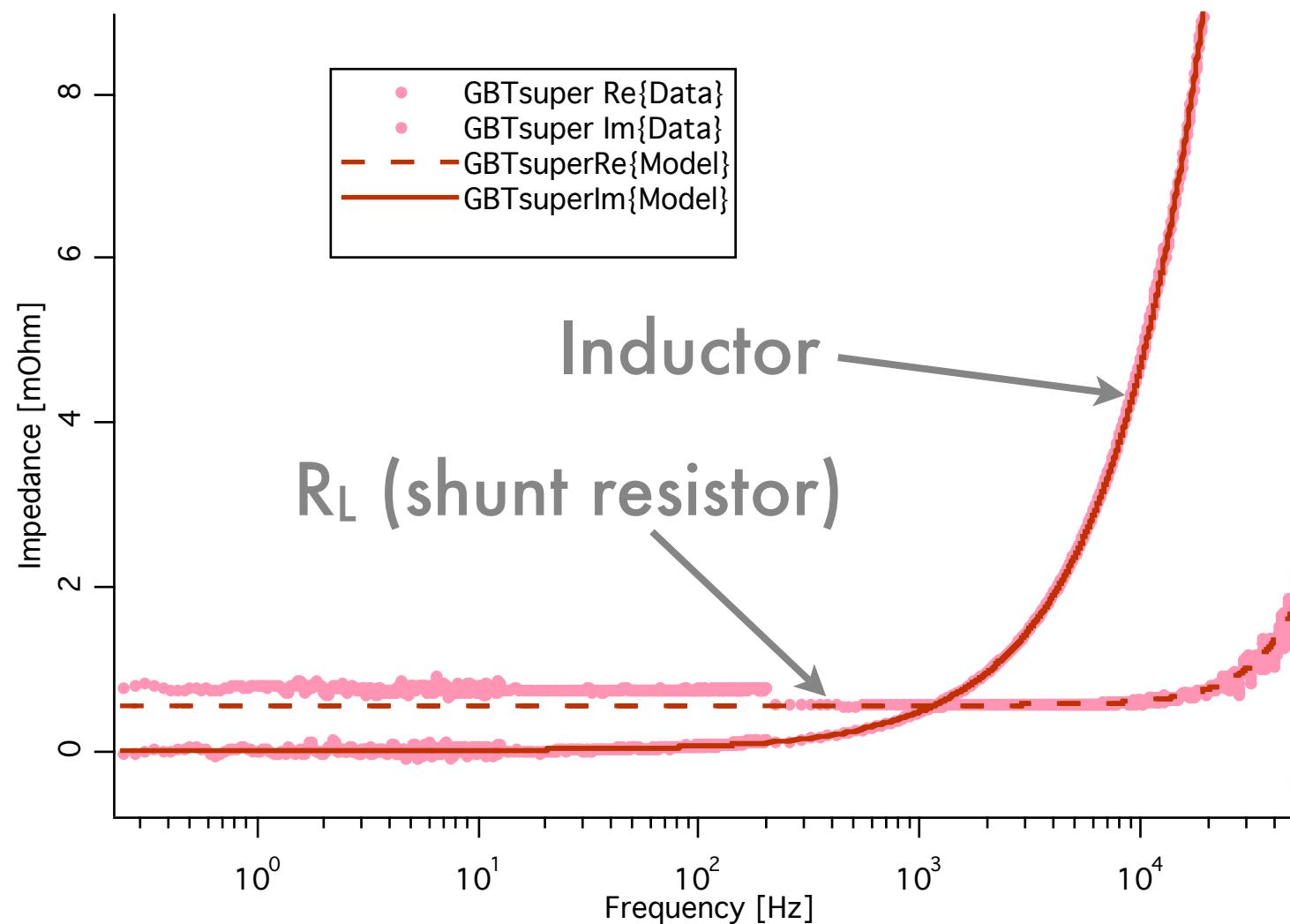


Circuit Parameters

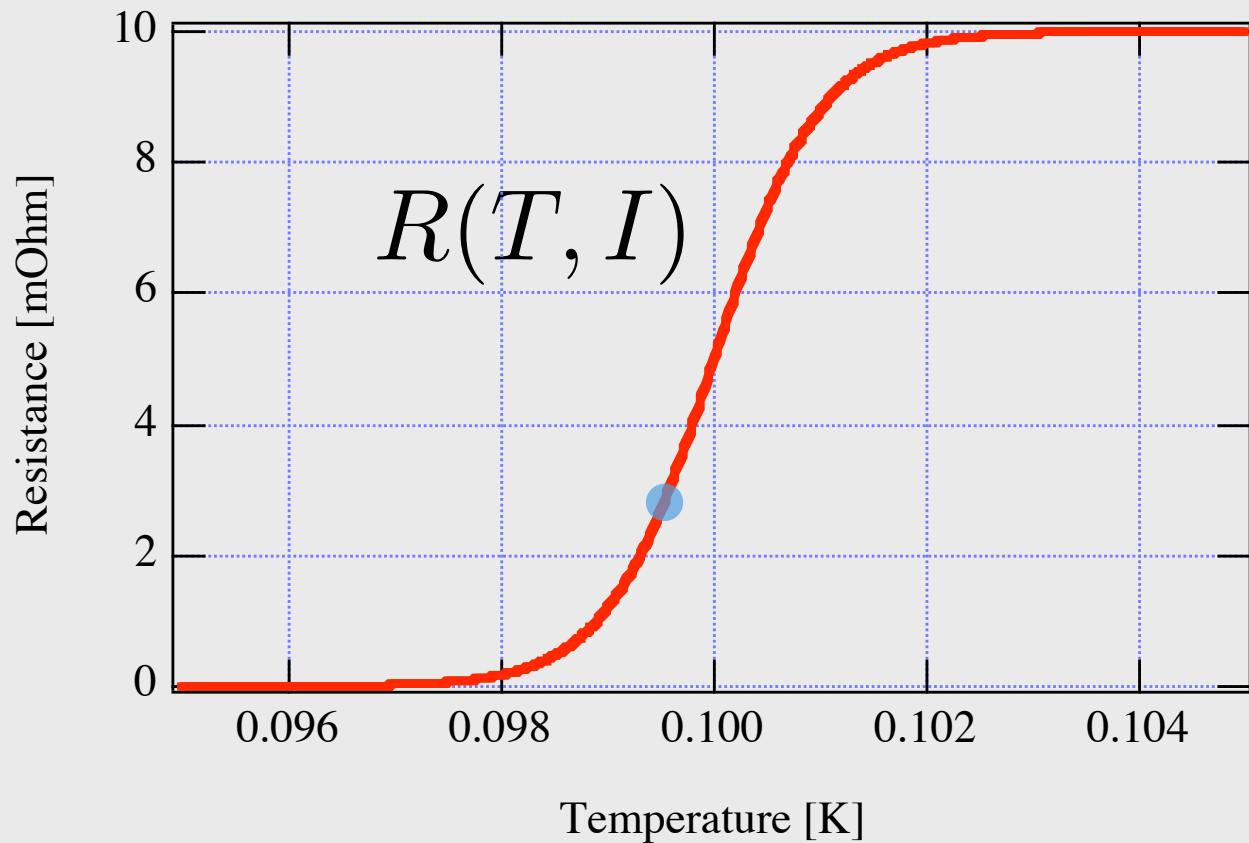


- $R_L = 0.55 \text{ mOhm}$
- $L = 74 \text{ nH}$
- $R_n = 7.3 \text{ mOhm}$

Fitting to $R_{\text{TES}} = 0$ Data



TES Parameters

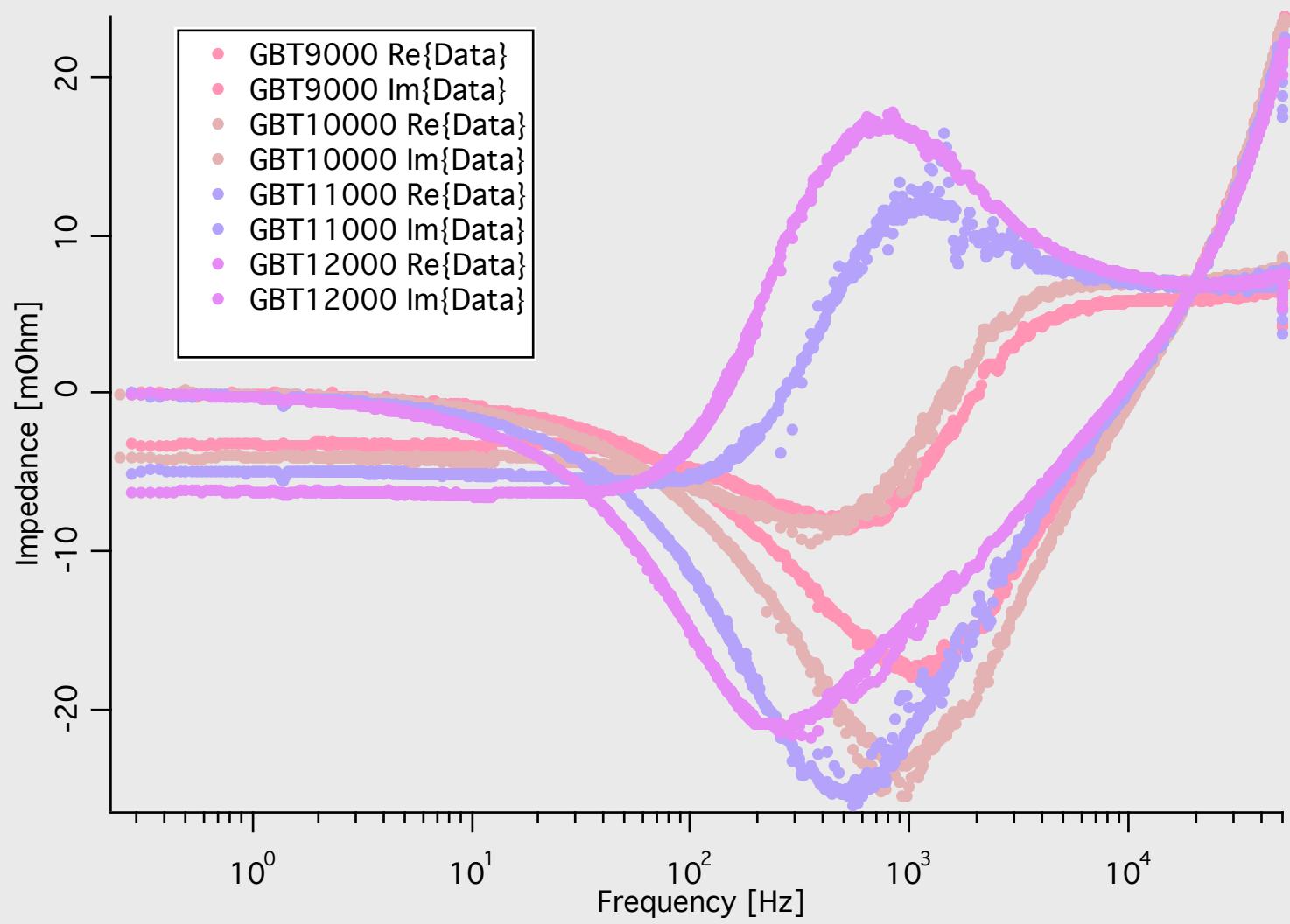


$$\alpha = \frac{T}{R} \frac{\partial R(T, I)}{\partial T} \Big|_{I=\text{const}} \quad \beta_i = \frac{I}{R} \frac{\partial R(T, I)}{\partial I} \Big|_{T=\text{const}}$$

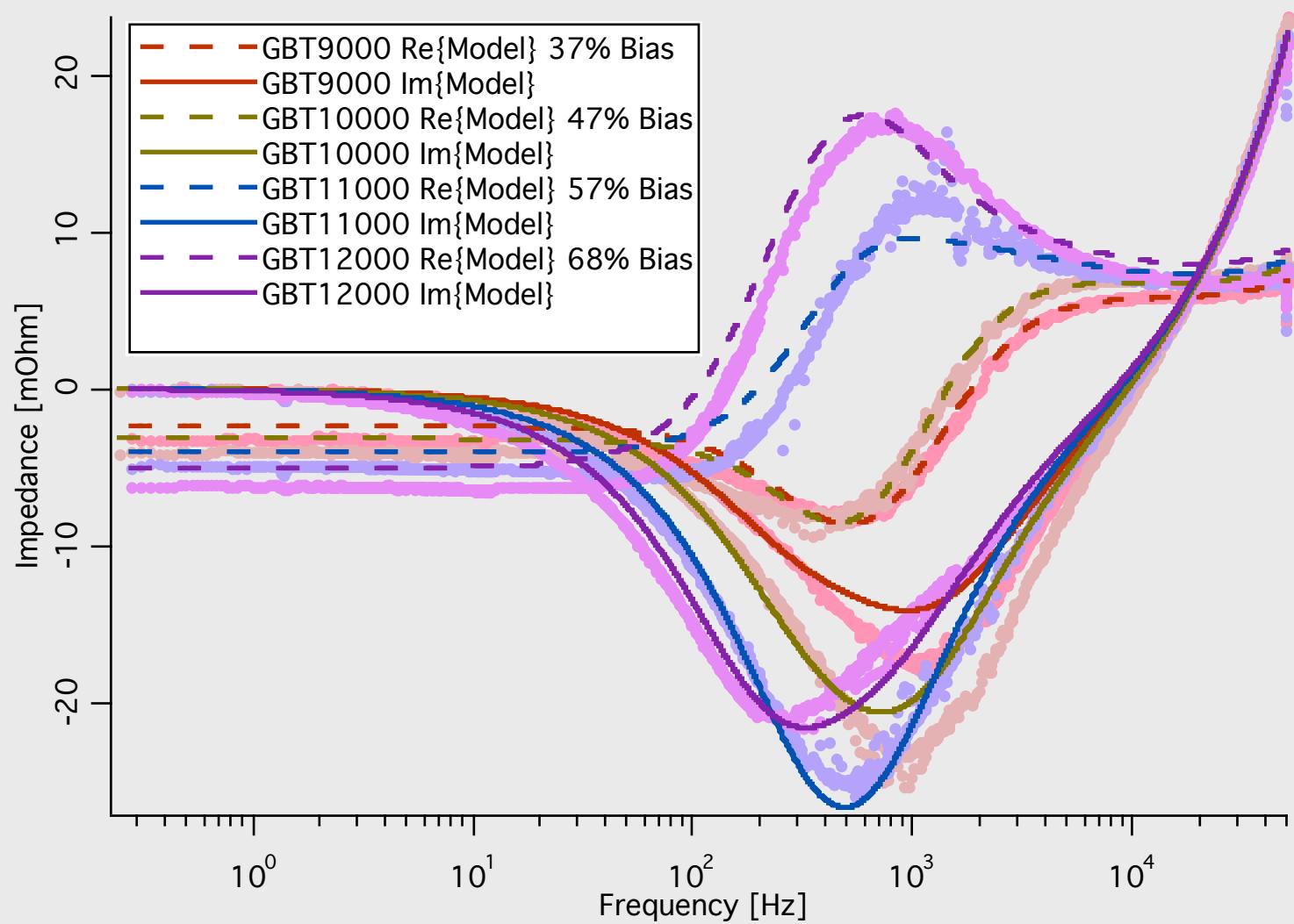
Results before fitting

Parameters	Values	Unknown
C_e (TES)	160 fJ/K	C_a (Bi) (est: 1.6-2.2 pJ/K)
C_p (Si)	650 fJ/K	
G_{ep}	5 nW/K	G_{ap}
G_{pb}	140 pW/K	alpha
T_c	484 mK	beta
T_b	298 mK	
R_n	8.28 mOhm	
R_L (shunt)	.055 mOhm	
L (inductor)	74 nH	

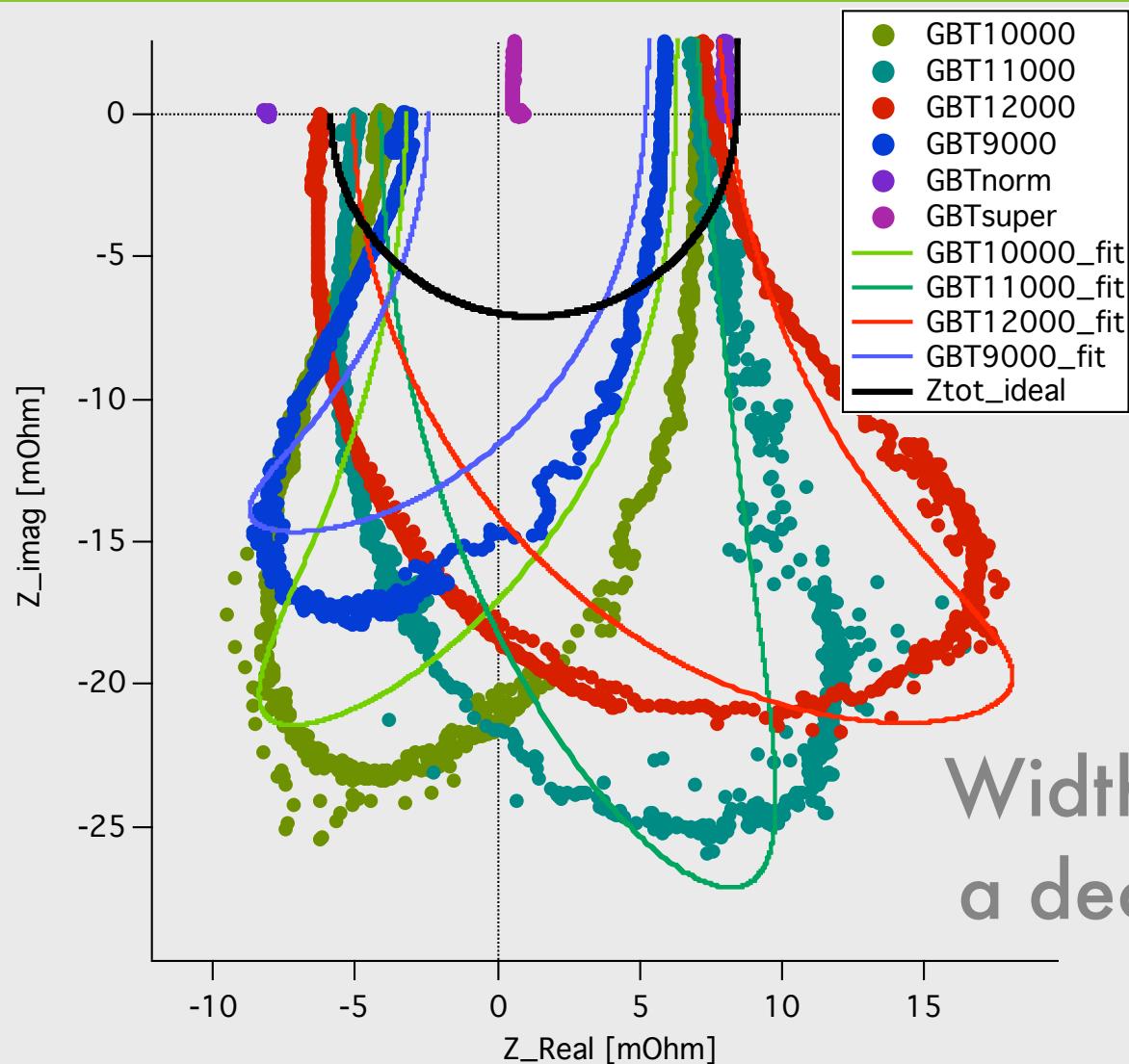
The Data



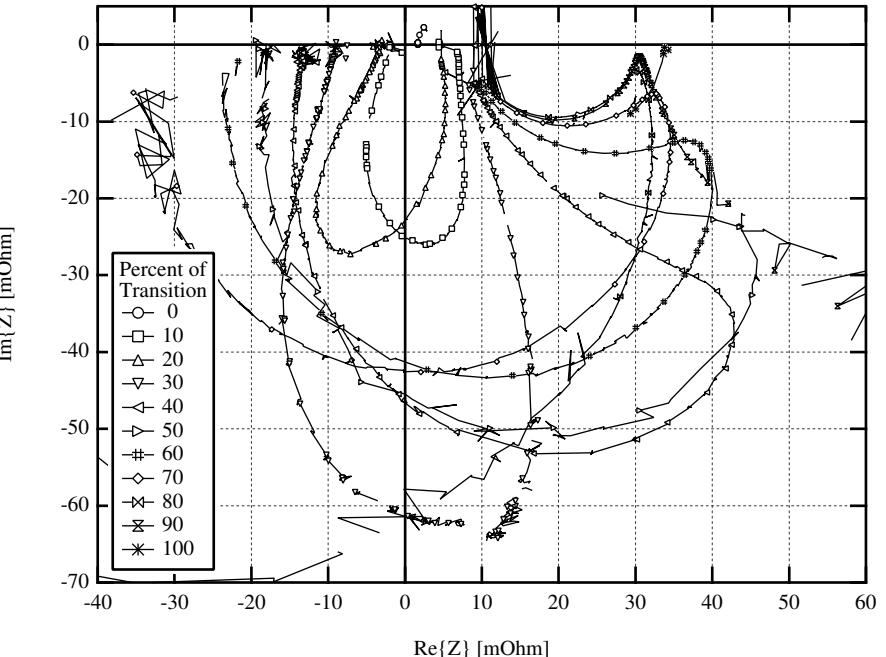
The Fits



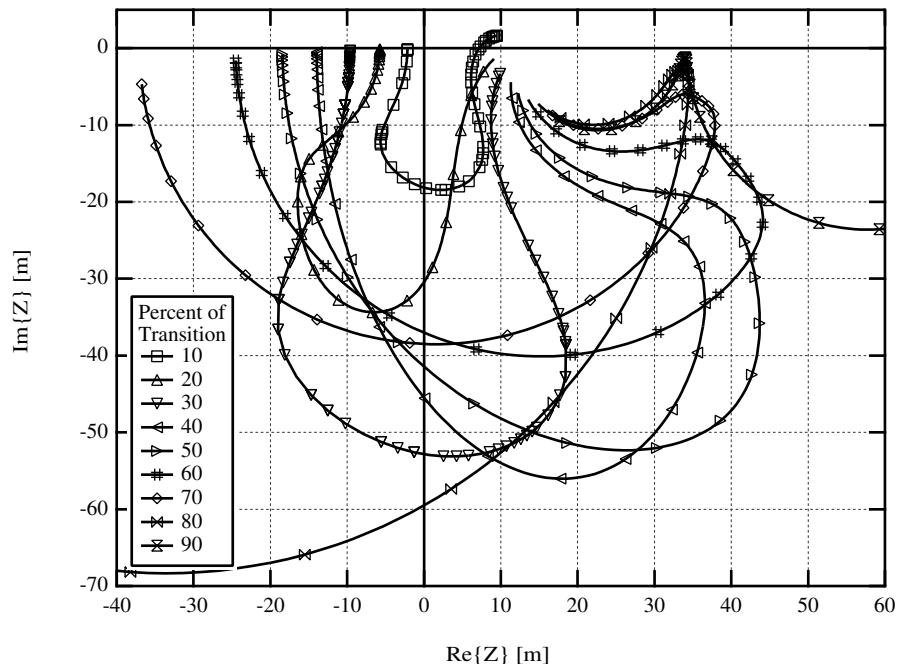
Imaginary vs Real



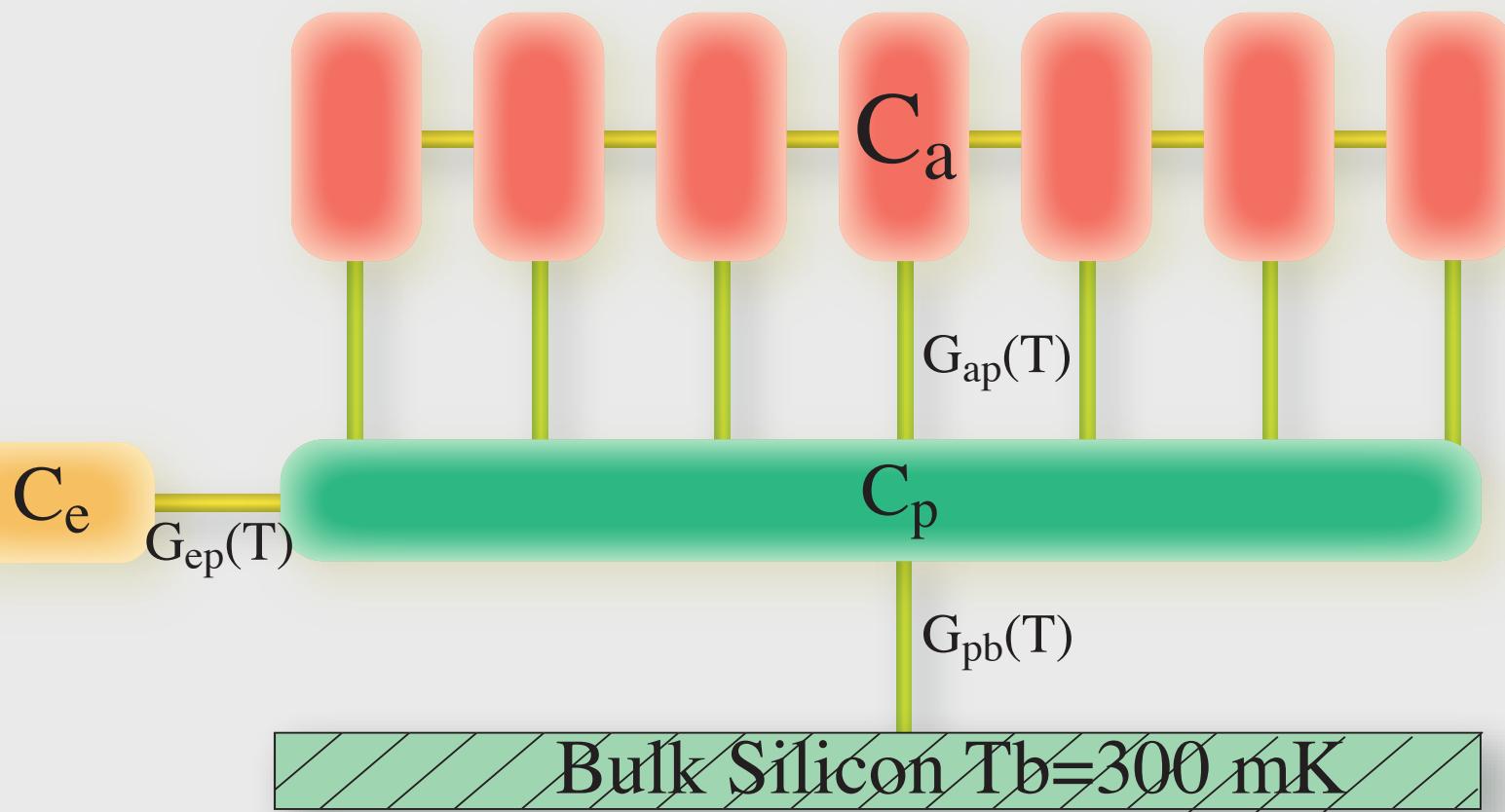
X-ray position-sensitive TES impedance data Distributed Absorbers!



(a) Impedance data for segmented Bi/Cu mushroom-absorber Post



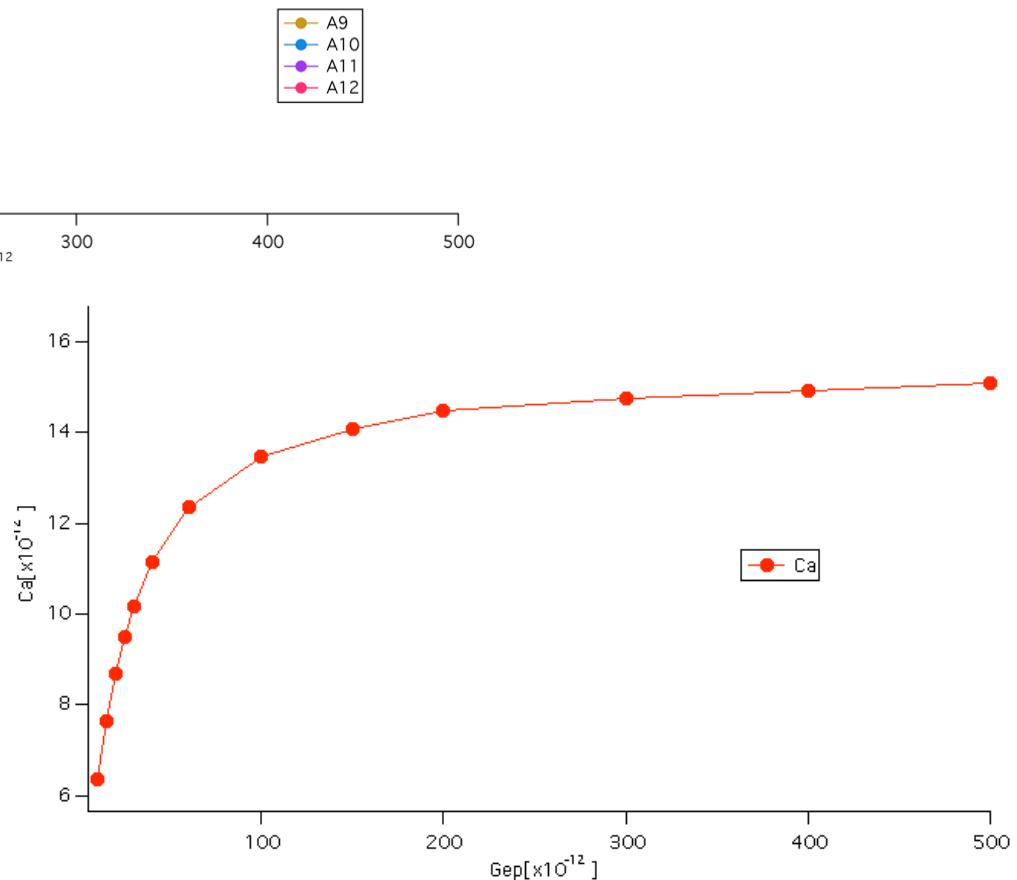
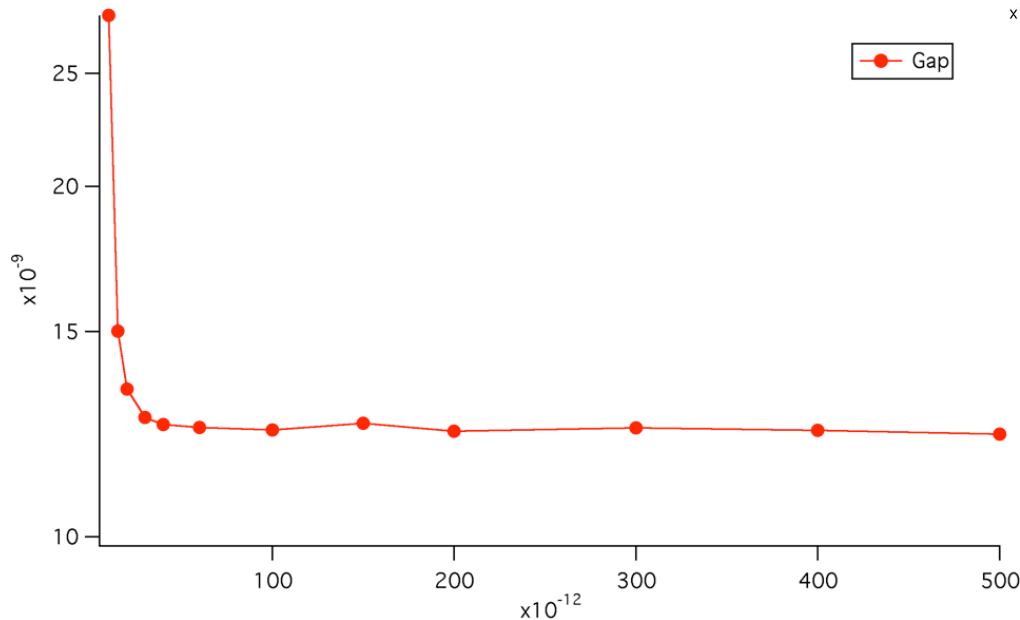
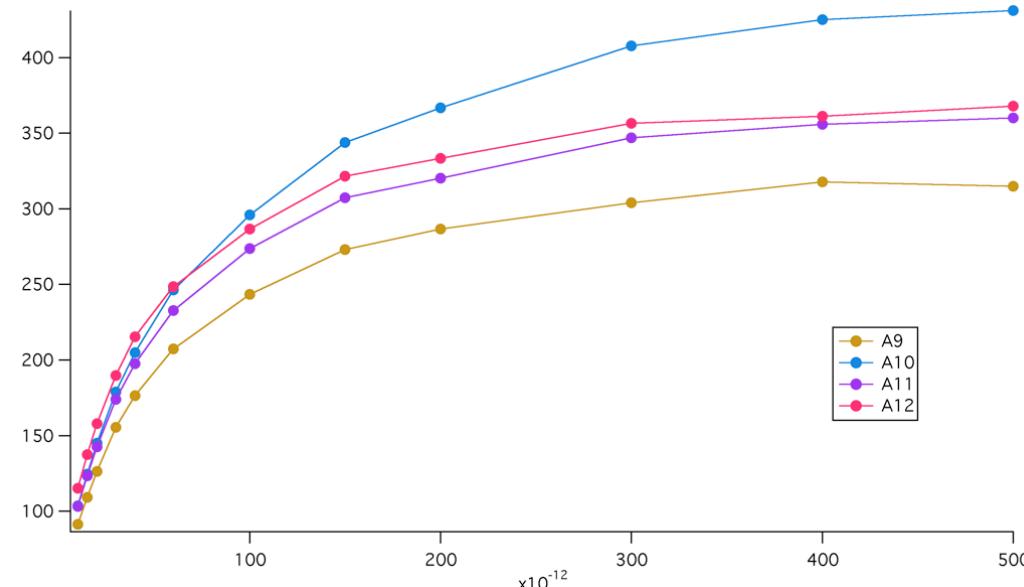
Distributed Model



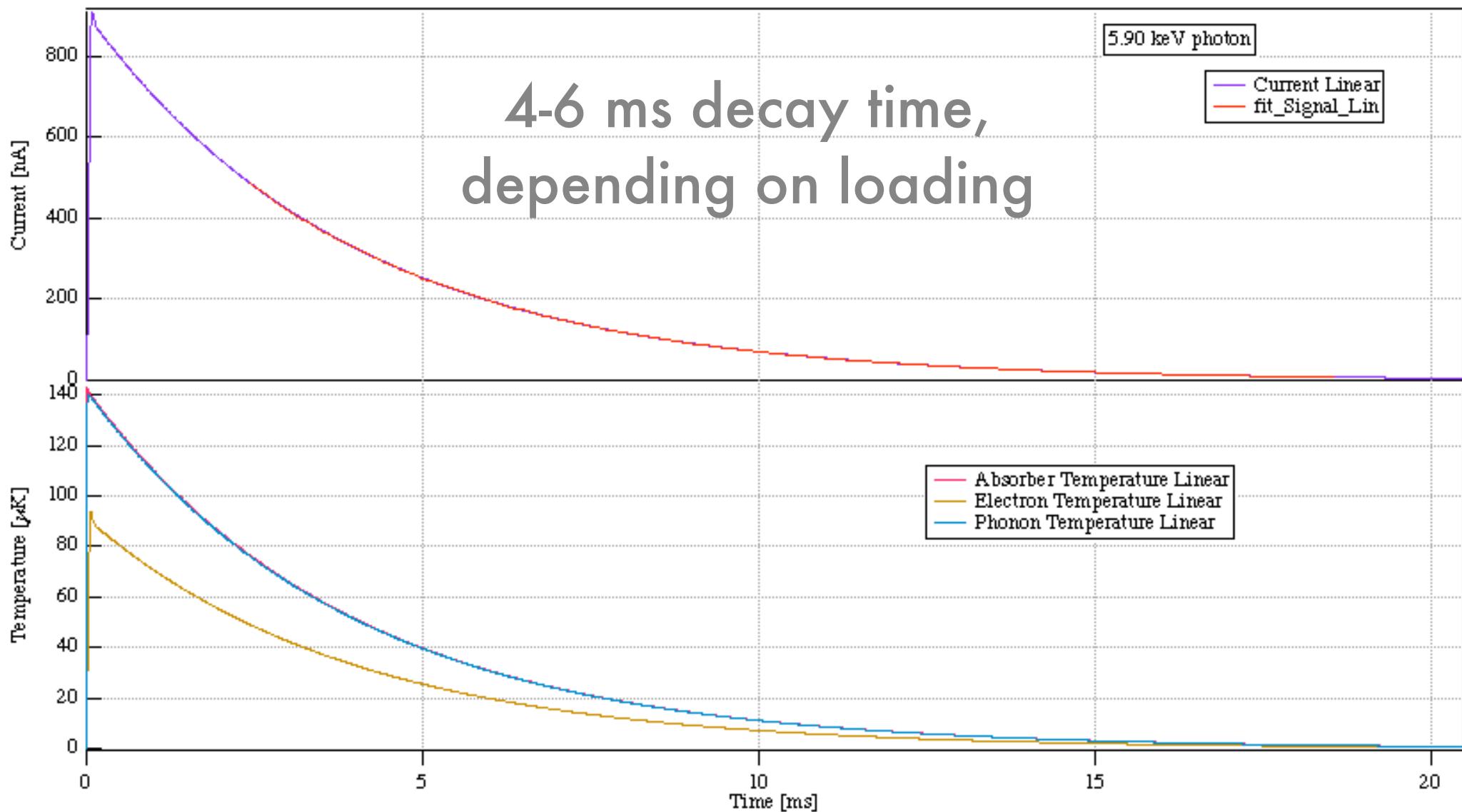
Modeling Results

Calc. Pars	Values	Fitted Pars	Values
C_e (TES)	160 fJ/K	C_a (Bi)	4 pJ/K
C_p (Si)	650 fJ/K	G_{ap}	8.7 nW/K
G_{ep}	5 nW/K	alpha	170
G_{pb}	140 pW/K	beta	0.9
T_c	484 mK		
T_b	298 mK	<i>Values at operating point</i>	
R_n	8.28 s mOhm		
R_L (shunt)	.055 mOhm		
L (inductor)	74 nH		

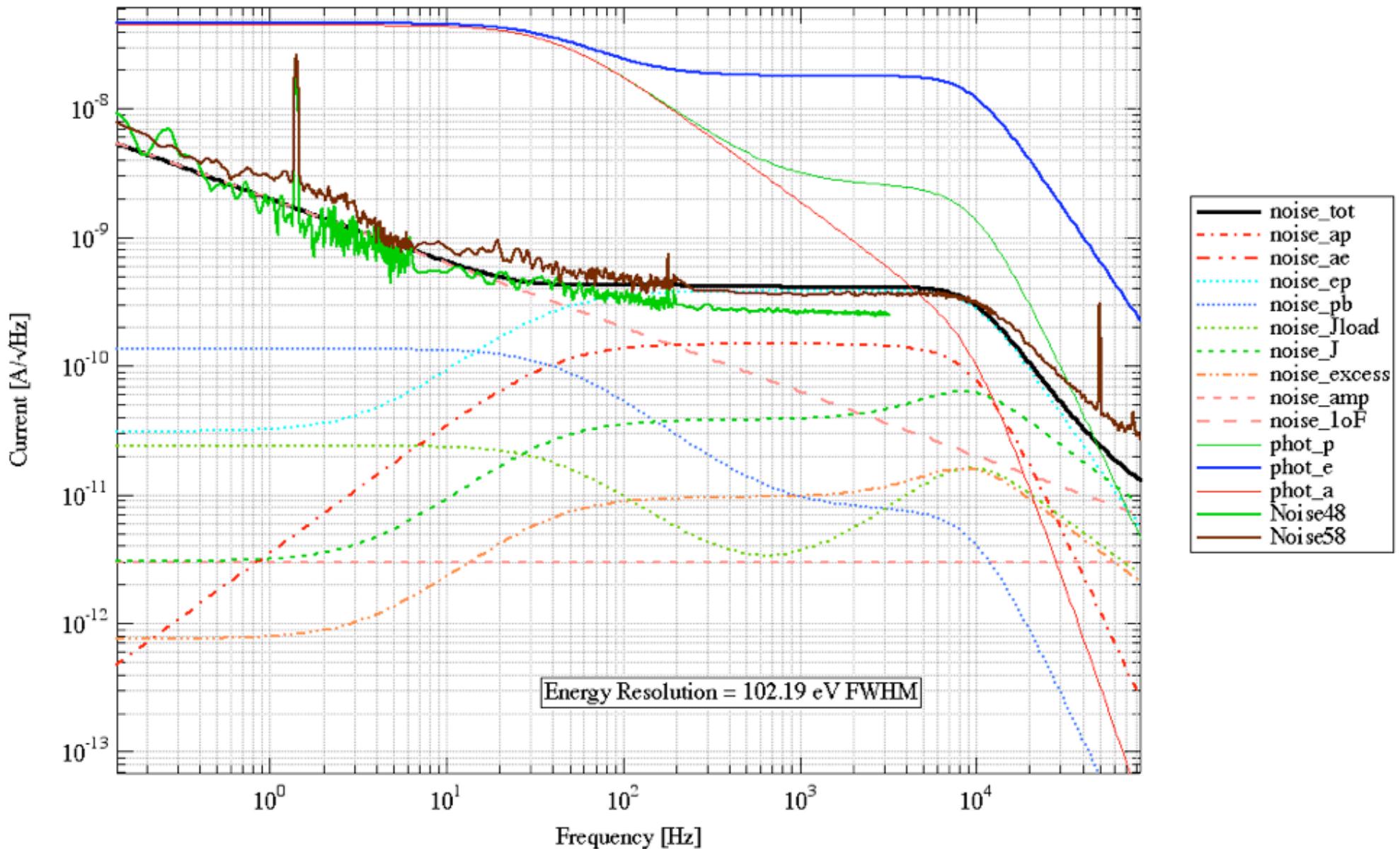
Variation as func. of G_{ep}



Time Constants



Noise



NEP

